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NEWS 1 Web Page URLs for STN Seminar Schedule - N. America  
 NEWS 2 "Ask CAS" for self-help around the clock  
 NEWS 3 Feb 24 PCTGEN now available on STN  
 NEWS 4 Feb 24 TEMA now available on STN  
 NEWS 5 Feb 26 NTIS now allows simultaneous left and right truncation  
 NEWS 6 Feb 26 PCTFULL now contains images  
 NEWS 7 Mar 04 SDI PACKAGE for monthly delivery of multifile SDI results  
 NEWS 8 Mar 24 PATDPAFULL now available on STN  
 NEWS 9 Mar 24 Additional information for trade-named substances without  
 structures available in REGISTRY  
 NEWS 10 Apr 11 Display formats in DGENE enhanced  
 NEWS 11 Apr 14 MEDLINE Reload  
 NEWS 12 Apr 17 Polymer searching in REGISTRY enhanced  
 NEWS 13 Jun 13 Indexing from 1947 to 1956 added to records in CA/CAPLUS  
 NEWS 14 Apr 21 New current-awareness alert (SDI) frequency in  
 WPIDS/WPINDEX/WPIX  
 NEWS 15 Apr 28 RDISCLOSURE now available on STN  
 NEWS 16 May 05 Pharmacokinetic information and systematic chemical names  
 added to PHAR  
 NEWS 17 May 15 MEDLINE file segment of TOXCENTER reloaded  
 NEWS 18 May 15 Supporter information for ENCOMPPAT and ENCOMPLIT updated  
 NEWS 19 May 19 Simultaneous left and right truncation added to WSCA  
 NEWS 20 May 19 RAPRA enhanced with new search field, simultaneous left and  
 right truncation  
 NEWS 21 Jun 06 Simultaneous left and right truncation added to CBNB  
 NEWS 22 Jun 06 PASCAL enhanced with additional data  
 NEWS 23 Jun 20 2003 edition of the FSTA Thesaurus is now available  
 NEWS 24 Jun 25 HSDB has been reloaded  
 NEWS 25 Jul 16 Data from 1960-1976 added to RDISCLOSURE  
 NEWS 26 Jul 21 Identification of STN records implemented  
 NEWS 27 Jul 21 Polymer class term count added to REGISTRY  
 NEWS 28 Jul 22 INPADOC: Basic index (/BI) enhanced; Simultaneous Left and  
 Right Truncation available

NEWS EXPRESS April 4 CURRENT WINDOWS VERSION IS V6.01a, CURRENT  
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FILE 'USPAT2' ENTERED AT 14:14:42 ON 05 AUG 2003  
CA INDEXING COPYRIGHT (C) 2003 AMERICAN CHEMICAL SOCIETY (ACS)

=> s Blomquist, Robert/in  
'IN' IS NOT A VALID FIELD CODE  
L1 18 BLOMQUIST, ROBERT/IN

=> s l1 and energy curable  
L2 1 L1 AND ENERGY CURABLE

=> d

L2 ANSWER 1 OF 1 PCTFULL COPYRIGHT 2003 Univentio on STN

Full  
Text

AN 2003011915 PCTFULL ED 20030228 EW 200307  
TIEN FLUORINATED OPTICAL POLYMER COMPOSITION  
TIFR COMPOSITION POLYMERE OPTIQUE FLUOREE  
IN **BLOMQUIST, Robert, 30 Birch Hill Drive, Whippany, NJ 07981, US**  
PA CORNING INCORPORATED, 1 Riverfront Plaza, Corning, NY 14831, US [US, US]  
AG SUGGS, James, V, CORNING INCORPORATED, Patent Department, SP TI 3-1,  
Corning, NY 14831, US  
LAF English  
LA English  
DT Patent  
PI WO 2003011915 A1 20030213  
DS W: AE AG AL AM AT AU AZ BA BB BG BR BY BZ CA CH CN CO CR CU CZ  
DE DK DM DZ EC EE ES FI GB GD GE GH GM HR HU ID IL IN IS JP  
KE KG KP KR KZ LC LK LR LS LT LU LV MA MD MG MK MN MW MX MZ  
NO NZ OM PH PL PT RO RU SD SE SG SI SK SL TJ TM TN TR TT TZ  
UA UG UZ VN YU ZA ZM ZW  
RW (EPO): AT BE CH CY DE DK ES FI FR GB GR IE IT LU MC NL PT SE TR  
AI WO 2002-US13673 A 20020429  
PRAI US 2001-09/912,827 20010725  
ICM C08F002-46  
ICS G03C001-73; G03C001-725; G03C005-00; G02B006-10

=> s energy curable, (aromatic or heteroaromatic moiety), fluorinat?, ethylenicallu u  
MISSING OPERATOR 'CURABLE, (AROMATIC'  
The search profile that was entered contains terms or  
nested terms that are not separated by a logical operator.

=> s energy curable and (aromatic or heteroaromatic moiety)  
L3 263 ENERGY CURABLE AND (AROMATIC OR HETEROAROMATIC MOIETY)

=> s l3 and fluorinat?  
L4 52 L3 AND FLUORINAT?

=> s l4 and ethylenically unsaturated  
L5 19 L4 AND ETHYLENICALLY UNSATURATED

=> s 15 and initiator#  
L6 14 L5 AND INITIATOR#

=> s 16 and isocyanurate moiety  
L7 0 L6 AND ISOCYANURATE MOIETY

=> s 16 and isocyanurate  
L8 6 L6 AND ISOCYANURATE

=> s 18 and compound#  
L9 6 L8 AND COMPOUND#

=> s 19 and (polymer# or copolymer#)  
L10 6 L9 AND (POLYMER# OR COPOLYMER#)

=> s 110 and optical element#  
L11 0 L10 AND OPTICAL ELEMENT#

=> d 110 1-6

L10 ANSWER 1 OF 6 EUROPATFULL COPYRIGHT 2003 WILA on STN

Full  
Text

GRANTED PATENT - ERTEILTES PATENT - BREVET DELIVRE

AN 1025176 EUROPATFULL ED 20020605 EW 200221 FS PS  
TIEN PROTECTIVE FILMS AND COATINGS.  
TIDE SCHUTZSCHICHTEN UND BESCHICHTUNGEN.  
TIFR FILMS ET REVETEMENTS PROTECTEURS.  
IN BARRERA, Denise, A., P.O. Box 33427, Saint Paul, MN 55133-3427, US  
PA MINNESOTA MINING AND MANUFACTURING COMPANY, 3M Center, P.O. Box 33427,  
St. Paul, Minnesota 55133-3427, US  
SO Wila-EPS-2002-H21-T1  
DS R DE; R FR; R GB; R IT; R SE  
PIT EPB1 EUROPAEISCHE PATENTSCHRIFT (Internationale Anmeldung)  
PI EP 1025176 B1 20020522  
OD 20000809  
AI EP 1998-951044 19981013  
PRAI US 1997-949367 19971014  
RLI WO 98-US21514 981013 INTAKZ  
WO 9919414 990422 INTPNR  
REP US 4128600 A US 5009936 A  
IC ICM C09J007-02  
ICS B32B027-08

L10 ANSWER 2 OF 6 EUROPATFULL COPYRIGHT 2003 WILA on STN

Full  
Text

PATENT APPLICATION - PATENTANMELDUNG - DEMANDE DE BREVET

AN 376655 EUROPATFULL ED 20000910 EW 199027 FS OS STA B  
TIEN Photographic element and preparation thereof.  
TIDE Photographisches Element und dessen Herstellung.  
TIFR Element photographique et sa preparation.  
IN Kobayashi, Tohru Konica Corporation, 26-2 Nishi-shinjuku 1-chome  
Shinjuku-ku, Tokyo, JP;  
Nishi, Yasuo Konica Corporation, 26-2 Nishi-shinjuku 1-chome  
Shinjuku-ku, Tokyo, JP;  
Nakano, Nakaya Konica Corporation, 26-2 Nishi-shinjuku 1-chome  
Shinjuku-ku, Tokyo, JP;  
Ohkawa, Kazuo c/o Asahi Denka Kogyo K.K., 2-35 Higashi-ogu 7-chome

Arawaka-ku, Tokyo, JP;  
Tachikawa, Hiroyuki c/o Asahi Denka Kogyo K.K., 2-35 Higashi-ogu 7-chome  
Arawaka-ku, Tokyo, JP  
PA KONICA CORPORATION, No. 26-2, Nishishinjuku 1-chome Shinjuku-ku, Tokyo,  
JP;  
ASAHI DENKA KOGYO KABUSHIKI KAISHA, 2-35, Higashiogu 7-chome, Arakawa-ku  
Tokyo 116, JP  
SO Wila-EPZ-1990-H27-T2  
DS R DE; R GB; R NL  
PIT EPA2 EUROPÄISCHE PATENTANMELDUNG  
PI EP 376655 A2 19900704  
OD 19900704  
AI EP 1989-313525 19891222  
PRAI JP 1988-335608 19881229  
IC ICM G03C011-08

GRANTED PATENT - ERTEILTES PATENT - BREVET DELIVRE

AN 376655 EUROPATFULL UP 20010712 EW 199540 FS PS STA B  
TIEN Photographic element and preparation thereof.  
TIDE Photographisches Element und dessen Herstellung.  
TIFR Element photographique et sa preparation.  
IN Kobayashi, Tohru Konica Corporation, 26-2 Nishi-shinjuku 1-chome  
Shinjuku-ku, Tokyo, JP;  
Nishi, Yasuo Konica Corporation, 26-2 Nishi-shinjuku 1-chome  
Shinjuku-ku, Tokyo, JP;  
Nakano, Nakaya Konica Corporation, 26-2 Nishi-shinjuku 1-chome  
Shinjuku-ku, Tokyo, JP;  
Ohkawa, Kazuo c/o Asahi Denka Kogyo K.K., 2-35 Higashi-ogu 7-chome  
Arawaka-ku, Tokyo, JP;  
Tachikawa, Hiroyuki c/o Asahi Denka Kogyo K.K., 2-35 Higashi-ogu 7-chome  
Arawaka-ku, Tokyo, JP  
PA KONICA CORPORATION, 26-2, Nishishinjuku 1-chome, Shinjuku-ku, Tokyo 160,  
JP;  
ASAHI DENKA KOGYO KABUSHIKI KAISHA, 2-35, Higashiogu 7-chome, Arakawa-ku  
Tokyo 116, JP  
SO Wila-EPS-1995-H40-T2  
DS R DE; R GB; R NL  
PIT EPB1 EUROPÄISCHE PATENTSCHEFT  
PI EP 376655 B1 19951004  
OD 19900704  
AI EP 1989-313525 19891222  
PRAI JP 1988-335608 19881229  
REP US 4426431 A  
REN PATENT ABSTRACTS OF JAPAN, vol. 11, no. 201 (P-500) (2648) 30 June 1987 &  
JP-A-62 021 150 Ronald S. Bauer (ED) 'Epoxy Resin Chemistry' 1981,  
American Chemical Society, Washington US, Chapter 2, "Photosensitized  
epoxides as basis for light-curable coatings", pp. 17-45  
IC ICM G03C011-08

L10 ANSWER 3 OF 6 PCTFULL COPYRIGHT 2003 Univentio on STN

Full  
Text

AN 2002090412 PCTFULL ED 20021121 EW 200246  
TIEN **ENERGY CURABLE** ADDUCT CONTAINING A FLUORO GROUP AND COATINGS THEREFROM  
TIFR PRODUIT D'ADDITION POUVANT ETRE DURCI PAR DE L'ENERGIE, CONTENANT UN  
GROUPE FLUORO, ET REVETEMENTS FABRIQUES A PARTIR DUDIT PRODUIT  
IN BIRCH, Adrian, J., La Traviata, Slnt-Jansteen 4564ER, NL [GB, NL];  
DUFF, Alan, W., Saxhavenstraat 10, Hulst 4561HC, NL [GB, NL];  
BARTELINK, Camiel, F., Robijnboog 31, Terneuzen 4533BA, NL [NL, NL]  
PA DOW GLOBAL TECHNOLOGIES INC., Washington Street, 1790 Building, Midland,  
MI 48674, US [US, US], for all designates States except US;  
BIRCH, Adrian, J., La Traviata, Slnt-Jansteen 4564ER, NL [GB, NL], for  
US only;

DUFF, Alan, W., Saxhavenstraat 10, Hulst 4561HC, NL [GB, NL], for US only;  
 BARTELINK, Camiel, F., Robijnboog 31, Terneuzen 4533BA, NL [NL, NL], for US only  
 AG ULMER, Duane, C., The Dow Chemical Company, Intellectual Property, B-1211, 2301 North Brazosport Boulevard, Freeport, TX 77541, US  
 LAF English  
 LA English  
 DT Patent  
 PI WO 2002090412 A1 20021114  
 DS W: AE AG AL AM AT AU AZ BA BB BG BR BY BZ CA CH CN CO CR CZ DE DK DM DZ EC EE ES FI GB GD GE GH GM HR HU ID IL IN IS JP KE KG KR KZ LC LK LR LS LT LU LV MA MD MG MK MN MW MX MZ NO NZ OM PH PL PT RO RU SD SE SG SI SK SL TJ TM TN TR TT TZ UA UG US UZ YU ZA ZM ZW  
 RW (ARIPO): GH GM KE LS MW MZ SD SL SZ TZ UG ZM ZW  
 RW (EAPO): AM AZ BY KG KZ MD RU TJ TM  
 RW (EPO): AT BE CH CY DE DK ES FI FR GB GR IE IT LU MC NL PT SE TR  
 RW (OAPI): BF BJ CF CG CI CM GA GN GQ GW ML MR NE SN TD TG  
 AI WO 2002-US14309 A 20020507  
 PRAI US 2001-60/289,344 20010507  
 ICM C08G018-10  
 ICS C08G018-28; C08G018-67; C08G018-48; C08G018-75

L10 ANSWER 4 OF 6 PCTFULL COPYRIGHT 2003 Univentio on STN

Full  
Text

AN 1999019414 PCTFULL ED 20020515  
 TIEN PROTECTIVE FILMS AND COATINGS  
 TIFR FILMS ET REVETEMENTS PROTECTEURS  
 IN BARRERA, Denise, A.  
 PA MINNESOTA MINING AND MANUFACTURING COMPANY  
 LA English  
 DT Patent  
 PI WO 9919414 A1 19990422  
 DS W: AL AM AT AU AZ BA BB BG BR BY CA CH CN CU CZ DE DK EE ES FI GB GD GE GH GM HR HU ID IL IS JP KE KG KP KR KZ LC LK LR LS LT LU LV MD MG MK MN MW MX NO NZ PL PT RO RU SD SE SG SI SK SL TJ TM TR TT UA UG UZ VN YU ZW GH GM KE LS MW SD SZ UG ZW AM AZ BY KG KZ MD RU TJ TM AT BE CH CY DE DK ES FI FR GB GR IE IT LU MC NL PT SE BF BJ CF CG CI CM GA GN GW ML MR NE SN TD TG  
 AI WO 1998-US21514 A 19981013  
 PRAI US 1997-08/949,367 19971014  
 ICM C09J007-02  
 ICS B32B027-08

L10 ANSWER 5 OF 6 USPATFULL on STN

Full  
Text

Citing  
References

AN 1999:124593 USPATFULL  
 TI Protective films and coatings  
 IN Barrera, Denise A., Oakdale, MN, United States  
 PA Minnesota Mining and Manufacturing Company, St. Paul, MN, United States (U.S. corporation)  
 PI US 5965256 19991012  
 AI US 1997-949367 19971014 (8)  
 DT Utility  
 FS Granted  
 LN.CNT 1325  
 INCL INCLM: 428/354.000  
 INCLS: 428/201.000; 428/203.000; 428/204.000; 428/421.000; 428/422.000; 428/423.100; 428/424.200; 428/424.400; 428/522.000; 427/487.000; 427/508.000; 427/521.000; 427/522.000; 427/407.100; 526/245.000;

525/123.000; 525/126.000

NCL NCLM: 428/354.000  
 NCLS: 427/407.100; 427/487.000; 427/508.000; 427/521.000; 427/522.000;  
 428/201.000; 428/203.000; 428/204.000; 428/421.000; 428/422.000;  
 428/423.100; 428/424.200; 428/424.400; 428/522.000; 525/123.000;  
 525/126.000; 526/245.000

IC [6]  
 ICM: B32B027-08  
 ICS: B32B027-16; B32B027-30; B32B027-40

EXF 428/201; 428/202; 428/203; 428/353; 428/354; 428/421; 428/422;  
 428/423.1; 428/424.2; 428/424.4; 428/522; 526/245; 525/123; 525/126;  
 427/487; 427/508; 427/521; 427/407.1

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L10 ANSWER 6 OF 6 USPATFULL on STN

Full Text	Citing References
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AN 93:3477 USPATFULL

TI Method of making photographic element having epoxy overlayer

IN Kobayashi, Tohru, Hino, Japan  
 Nishi, Yasuo, Hino, Japan  
 Nakano, Nakaya, Hino, Japan  
 Ohkawa, Kazuo, Tokyo, Japan  
 Tachikawa, Hiroyuki, Tokyo, Japan

PA Konica Corporation, Tokyo, Japan (non-U.S. corporation)  
 Asahi Denka Kogyo K.K., Tokyo, Japan (non-U.S. corporation)

PI US 5178996 19930112

AI US 1992-897578 19920611 (7)

RLI Continuation of Ser. No. US 1991-670371, filed on 14 Mar 1991, now  
 abandoned which is a continuation of Ser. No. US 1989-458303, filed on  
 28 Dec 1989, now abandoned

PRAI JP 1988-335608 19881229

DT Utility

FS Granted

LN.CNT 986

INCL INCLM: 430/532.000  
 INCLS: 427/331.000; 430/271.000; 430/273.000; 430/523.000; 430/531.000;  
 430/961.000

NCL NCLM: 430/532.000  
 NCLS: 427/331.000; 430/271.100; 430/273.100; 430/523.000; 430/531.000;  
 430/961.000

IC [5]  
 ICM: G03C001-76

EXF 430/271; 430/273; 430/523; 430/531; 430/532; 430/961; 427/331

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

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